

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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Am. Mt  
A

In re Patent Application of: )  
RAINERI ET AL. )  
Serial No. Not Yet Assigned )  
Filing Date: Herewith )  
For: A METHOD FOR MANUFACTURING )  
ISOLATING STRUCTURES )

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G. Stanley  
3-27-03

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DATE OF DEPOSIT: February 20, 2002

NAME: Dawn Kimler

SIGNATURE: Dawn Kimler

PRELIMINARY AMENDMENT

Director, U.S. Patent and Trademark Office  
Washington, D.C. 20231

Sir:

Prior to the calculation of fees and examination of  
the present application, please enter the amendments and  
remarks set out below.

In the Drawings:

Submitted herewith is a request for a proposed  
drawing modification as indicated in red ink to add a missing  
reference numeral and to remove an extraneous marking from  
FIG. 2. FIGS. 1 and 3-20 are also being modified as indicated  
in red ink to remove extraneous markings therefrom.

In the Specification:

Please replace the paragraph beginning at page 2,  
line 13, with the following rewritten paragraph:

-- One aspect of the invention is directed to a  
method for forming isolating structures in a silicon carbide  
layer. The method comprises depositing a masking layer on

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